Supplementary

EMPAD detector specifications					
Sensor dimensions	Active area Pixels Pixel size Active thickness	19.2x19.2 mm 128x128 150 μm x150 μm 500 μm			
Performance	DQE(0): Dynamic range Well capacity SNR Minimum integration time High-tension range	0.96@60 keV, 0.95@80 keV and 0.94@300 keV 10 ⁶ :1 @200 keV 2 pA/pixel @ 200 keV 140 @200 keV 30 µs 30-300 keV			
Maximum speed	1100 fps (128x128 pixel)				
Radiation hardness	@300 kV > 10 ¹² e/pixel				
Storage capacity	4TB SATA 7200rps HDD				
Control and imaging software	Scan control for field of view and dwell time				
	 Live synthesized STEM image via online data processing of user-defined masks for ABF, BF, DF, HAADF, iCOM and DPCx, DPCy 				
	Live single (or series) diffraction patterns				
	 Supportive live view annotations to set up and reproduce experiments quickly 				
	 Advanced data management to keep track of experimental metadata 				
	Save raw data and live analysis of results				
	Offline analysis of projects on your laptop				
System requirements	Talos/Spectra with Windows® 10				
Retrofit	For retrofits on your tool contact sales and service organization in your region				

	Primary Detector	Secondary Detector Options			
	К3	1069.FXUP	1069.EXUP	1069.LVUP	1069.STUP
Operating range (kV)	80 – 300	40 – 300	30 – 300	30 – 60*	30 – 200*
EFTEM imaging size (pixel x pixel)	6912 x 6912 [super resolution]		2048 x 2048		512 x 512
EELS energy channels (pixels)	3456		2048		1024
ω – q EELS (pixel x pixel)	3456 x 2048		2048 x 1024		1024 x 512
Detector technology	CMOS direct detection counted and linear	CMOS high-speed XCR™ fiber / scintillator	high bri	IOS ghtness / scintillator	Hybrid-pixel direct detection counted
Image frame rate (fps)					
Full-frame to memory	75		90		2000
Sub-area (in-situ option)	3500		180		16000
Spectroscopy	3000	8000	26	500	9000

^{*} X-ray safe to 300 kV

^{**} DualEELS and 100 ns blanker are standard for all detector options

^{***} In-situ and 4D STEM modes are optional for all detector options

ADVANTAGES

- Extends 4k x 4k camera leadership for imaging and in-situ data capture
- Always have a "live" experience with 25 fps at full 4k x 4k resolution, no compromise to resolution between viewing and recording images
- Guarantee optimal image quality with real-time drift correction and outlier removal using in-line data processing
- Detect single electrons with highest signal-to-noise ratio using the most sensitive scintillator and fiber optics available
- · Extend the dynamic range beyond 16-bits, no beam stop required
- Increase productivity, even for novice users, with intuitive, built-in workflows to support and optimize recording modes
- Available as the primary camera for TEMs manufactured by FEI*, Hitachi High Technologies, and JEOL

In-situ option

- Flexibly trade-off resolution against frame rate—from 4096 x 4096 pixels at 25 fps to 512 x 512 pixels at 300 fps, always at 100% duty cycle
- Video buffer allows you to capture only the video you want; with post-event triggering with LookBack feature
- Never miss the start of an in-situ reaction again
- Tailor videos to your unique applications with powerful post-processing tools

Specifications

TEM operating voltage (kV)	Up to 400		
Sensor active size (mm)	61.4 x 61.4		
Sensor size (pixels)	4096 x 4096		
Pixel size (µm)	15		
Full sensor read-out speed (fps)	25		
Image display (fps)	25		
Recording modes	Image Video (<i>in-situ</i> option)		
Image formats	1:1 (4k, 2k, 1k) 16:9 (UHD, HD)		
Video formats	1:1 (4k, 2k, 1k) 16:9 (UHD, HD)		
Image capture modes	Exposure time Signal-to-noise Specimen dose		
1:1 <i>in-situ</i> video capture speed (fps) 4096 x 4096 pixels 2048 x 2048 pixels 1024 x 1024 pixels	25 100 200		
16:9 <i>in-situ</i> video capture speed (fps) 3840 x 2160 pixels (UHD) 1920 x 1080 pixels (HD)	40 135		
Conversion efficiency @ 200 kV (counts/primary e ⁻)	>35		
DQE (200 kV, 4k x 4k) Quarter Nyquist (%) Half Nyquist (%)	>20 >10		
Dynamic range	>16-bit with frame accumulation		
GIF compatible	Yes		



Specifications are subject to change.

^{*} Contact your local sales representative for the latest embedding options.

■ Product development background

The recent transmission electron microscope (TEM) enables a sub-Å electron probe to be formed with a spherical aberration corrector (Cs corrector). Owing to Cs correction, atomic-resolution STEM has reached a general use along with various STEM detectors for diversified observation purposes. In STEM, the extremely small probe scans over the specimen and maps on each pixel signals of transmitted and diffracted electrons.

An innovative new detector "4DCanvas" records position and intensity of all the transmitted, diffracted and scattered electrons as a 2-dimensional (2D) pattern for every pixel of STEM image. The sensor of this pixelated detector is a direct electron detection CCD with 264×264 pixels. In other words, the detector acts as a highly sensitive multi-channel STEM detector with channels of 264×264 . The recorded data with this detector is 4-dimensional (4D) with axes of $x \times y$ of STEM pixel positions and u & v of detector pixel positions. "4DCanvas" is named after the dimensions of the acquired data with the detector. There have been several applications using the "4DCanvas".

- Visualization of magnetic/electric field vectors by recording a shift of a transmitted beam or the center of mass for each diffraction pattern.
- Since the user can create and assign an arbitrary-shaped detector on the detector plane, a STEM image is detected by the arbitrary-shaped detector. This unique capability enables high contrast imaging (e.g. differential phase contrast image).
- 3. By performing ptychography, a wave field of a transmitted electron beam can be reconstructed. Thus, we can observe a phase image of a sample with high efficiency. Since the detector can compensate the phase on the diffraction plane, it enables us to correct aberrations by post-processing. A series of optically sectioned Z-sliced images can be obtained (defocus is one of aberrations). The aberration corrected image is also obtained through the post processing process.

The potential applications of "4DCanvas" are expected to be increasing. This revolutionized "4DCanvas" will offer a platform to users of electron microscopes as if they freely draw a map on the canvas.



Main Features

1. JEOL pixelated STEM detector

High read-out rate of the detector enables fast acquisition of STEM images. Its signal-to-noise ratio is as high as 300:1. The quantum efficiency of this sensor is almost 100%, since the pixel size in x, y and z is large enough to detect all incoming electrons. Thus, the pixelated detector is very suitable for low-dose imaging. Furthermore, the detector functions as a high-speed and highly-sensitive direct electron detection camera for TEM imaging.

2. Optimum mounting position of the detector

"4DCanvas" is placed beneath the viewing chamber, thus simultaneous acquisition of the data for the HAADF (high-angle annular dark-field) STEM detector is possible, resulting in the comparison of images by a "4DCanvas" and a HAADF detector. Since the detector is retractable, various types of cameras can be attached in the opposite face of a housing chamber. An EELS (electron energy-loss spectrometer), which is mounted at the bottom of the microscope column, is usable by the retraction.

3. High-speed STEM data detection

"4DCanvas" achieves high-speed STEM image acquisition of 1,000 fps or higher, as are shown below, because the sensor is CCD, which is capable of binning.

1,000 fps (full-frame readout, 264 × 264 pixels)

STEM image acquisition time for 256 \times 256 pixels: 64 s

2,000 fps (1 × 2 binning, 264 × 132 pixels)

STEM image acquisition time for 256 \times 256 pixels: 32 s

4,000 fps (1 × 4 binning, 264 × 66 pixels)

STEM image acquisition time for 256 \times 256 pixels: 16 s

4. Detection of a wide range of accelerated electrons

"4DCanvas" can also detect a wide range of accelerated electrons, ranged from 30 kV to 300 kV. This feature enables us to optimize an accelerating voltage depending on the specimen. Thus, the detector is applicable to a specimen susceptible to electron-beam irradiation.

5. Installation of the pixelated detector, "4DCanvas"

"4DCanvas" can be installed into the JEM-ARM300F and the JEM-ARM200F.

Notice: In the near future, installation into the JEM-F200 will be possible.

Software

"4DCanvas" has software that creates synthetic STEM images reconstructed from the 4D data.

The software can map the amount and direction of beam shift for each electron probe position, resulting in a map of electric-magnetic fields vector, whose components are intensities and direction.